MNC 2018 (November 13-16, Sapporo Park Hotel, Sapporo, Japan) Schedule

Tuesday, November 13

Room C (The Terrass Room (1F))				
13:00-16:45 MNC 2018 Technical Seminar in Japanese				
EUV Lithography Tutorial				
Room F (Park Hall (3F)				
17:20-19:20 Get Together Party				

Wednesday, November 14 Room P1 (Emelald, 3F)

Technical Seminar in Japanese Registration Desk November 13, 12:30 - 16:00 (1F Lobby)

Conference Registration Desk November 13, 16:00 - 18:30 (1F Lobby) November 14, 8:30 - 11:30 (1F Lobby) November 14, 11:40 - 18:30 (B-2F Lobby in front of Room P2) November 15, 8:30 - 18:00 (B-2F Lobby in front of Room P2) November 16, 8:30 - 16:00 (B-2F Lobby in front of Room P2)

14P-1: Opening & Plenary Session 9:30-12:10		November 16, 8:30 - 16:00 (B-2F Lobby in front of Room P2)	
Lu	nch		
Room A (Park Plaza A (B2F)	Room B (Park Plaza D (B2F)	Room C (The Terrace Room (1F))	Room D (Emina (1F))
14A-2: 13:30-15:00	14B-2: 13:30-14:40	14C-2: 13:30-15:40	14D-2: 13:30-14:50
Symp. A: Nano-Metrology for Exploring the Limit I	Microsystem Technology and MEMS I	NanoTool I	Inorganic Nanomaterials I
Author's Interview: None	14B-2 Author's Interview: 16:35-16:45	14C-2 Author's Interview: 15:40-15:50	14D-2 Author's Interview: 16:45-16:55
	Room P2 (Park	Plaza BC (B2F))	
	Coffee	e Break	
14A-3: 15:15-16:45	14B-3: 14:55-16:35	14C-3: 16:05-17:15	14D-3: 15:05-16:45
Symp. A: Nano-Metrology for Exploring the Limit II	Microsystem Technology and MEMS II	Nanodevices I	Inorganic Nanomaterials II
Author's Interview: None	14B-3 Author's Interview: 16:35-16:45	14C-3 Author's Interview: 17:15-17:25	14D-3 Author's Interview: 16:45-16:55
	Room A (Park Plaza D (B2F) and	Room P2 (Park Plaza BC (B2F))	·

17:10-17:40 Happy Hour Part I, 17:40-18:40 Happy Hour Part II

Thursday, November 15						
Room A (Park Plaza A (B2F)	Room B (Park Plaza D (B2F)	Room C (The Terrace Room (1F))	Room D (Emina (1F))			
15A-4: 9:00-10:50	15B-4: 9:00-10:20	15C-4: 9:00-10:40	15D-4: 9:00-10:30			
Resist and Directed Self-Assembly	Nanocarbons I	Nanodevices II	Microsystem Technology and MEMS III			
15A-4 Author's Interview: 10:50-11:00	15B-4 Author's Interview: 10:20-10:30	15C-4 Author's Interview: 12:35-12:45	15D-4 Author's Interview: 10:30-10:40			
Room P2 (Park Plaza BC (B2F))						
Coffee Break						
15A-5: 11:10-12:40	15B-5: 10:45-12:05	15C-5: 10:55-12:35	15D-5: 10:55-12:15			
Electron and Ion Beam Technologies	Inorganic Nanomaterials III	Nanodevices III	Organic Nanomaterials I			
15A-5 Author's Interview: 12:40-12:50	15B-5 Author's Interview: 12:05-12:15	15C-5 Author's Interview: 12:35-12:45	15D-5 Author's Interview: 12:15-12:25			
Lunch						
15A-6: 14:10-15:40	15B-6: 13:50-15:30	15C-6: 13:40-15:50	15D-6: 13:40-14:40			
Photolithography and Patterning	Inorganic Nanomaterials IV	Symp. C: Thermal and Electronic Properties of Nanoscale Interfaces	Organic Nanomaterials II			
15A-6 Author's Interview: 15:40-15:50	15B-6 Author's Interview: 15:30-15:40	15C-6 Author's Interview: 15:50-16:00	15D-6 Author's Interview: 14:40-14:50			
Room P2 (Park Plaza BC (B2F))						
Coffee Break						
Room P2 (Park Plaza BC (B2F))						
15P-7: 16:00-18:00 Poster Session I Photolithography and Patterning Electron and Ion Beam Technologies, Resist and Directed Self-Assembly, Nanocarbons, Nanodevices, Nanofabrication						

Photolithography and Patterning, Electron and Ion Beam Technologies, Resist and Directed Self-Assembly, Nanocarbons, Nanodevices, Nanofabrication, Inorganic Nanomaterials, Organic Nanomaterials, NanoTool and Microsystem Technology and MEMS

Room P1 (Emelald, 3F)

Friday, November 16					
Room A (Park Plaza A (B2F)	Room B (Park Plaza D (B2F)	Room C (The Terrace Room (1F))	Room D (Emina (1F))		
16A-8: 9:00-11:00	16B-8: 9:00-10:30 Nanocarbons II	16C-8: 9:00-11:00	16D-8: 9:00-10:30		
Symp. B: Recent Progress of Atomic		Symp. D: BioMEMS, Lab on a Chip,	Nanofabrication I		
Layer Processing (ALP) Technology		and Nanobiotechnology			
Author's Interview: None	16B-8 Author's Interview: 12:05-12:15	Author's Interview: None	16D-8 Author's Interview: 11:50-12:00		
	Room P2 (Park	Plaza BC (B2F))			
Coffee Break					
16A-9: 11:15-12:25	16B-9: 10:45-12:05	16C-9: 11:15-12:15	16D-9: 10:50-11:50		
Nanoimprint, Hybrid-NIL, Biomimetics,	Nanocarbons III	BioMEMS, Lab on a Chip, and	Nanofabrication II		
and Functional Surfaces I		Nanobiotechnology I			
16A-9 Author's Interview: 12:25-12:35	16B-9 Author's Interview: 12:05-12:15	Author's Interview: None	16D-9 Author's Interview: 11:50-12:00		
Lunch					
16A-10: 13:50-15:20	16B-10: 13:30-15:20	16C-10: 13:30-15:10	16D-10: 13:40-15:00		
Nanoimprint, Hybrid-NIL, Biomimetics,	Nanocarbons IV	BioMEMS, Lab on a Chip, and	Nanofabrication III		
and Functional Surfaces II		Nanobiotechnology II			
16A-10 Author's Interview: 15:20-15:30	16B-10 Author's Interview: 15:20-15:30	16C-10 Author's Interview: 15:10-15:20	16D-10 Author's Interview: 15:00-15:10		
Room P2 (Park Plaza BC (B2F))					
16P-11: 15:30-17:30 Poster Session II					

16P-11: 15:30-17:30 Poster Session II

18:20-20:20 Banquet

Nanocarbons, Nanodevices, Nanofabrication, Inorganic Nanomaterials, Nanoimprint, Hybrid-NIL, Biomimetics, and Functional Surfaces and BioMEMS, Lab on a Chip, and Nanobiotechnology